L Number	Hits	Search Text	DB	Time stamp
- Number	51785	(mask\$3 or resist\$3 or photoresist) same	USPAT;	2003/06/03 09:04
	31,03	((etch\$3 or chemical\$2 adj mil\$3 or	US-PGPUB;	
,		deoxidiz\$3 or anodiz\$3) and metal)	EPO; JPO;	
			IBM TDB	
_	25136	((mask\$3 or resist\$3 or photoresist) same	USPĀT;	2003/06/03 09:05
	2020	((etch\$3 or chemical\$2 adj mil\$3 or	US-PGPUB;	
		deoxidiz\$3 or anodiz\$3) and metal)) and	EPO; JPO;	
		(mask\$3 or resist\$3 or photoresist) same	IBM_TDB	
		(aluminum or "Al" or steel or titanium or		
		"Ti")		
_	26	(((mask\$3 or resist\$3 or photoresist) same	USPAT;	2003/05/26 16:28
		((etch\$3 or chemical\$2 adj mil\$3 or	US-PGPUB;	
		deoxidiz\$3 or anodiz\$3) and metal)) and	EPO; JPO;	
		(mask\$3 or resist\$3 or photoresist) same	IBM_TDB	
		(aluminum or "Al" or steel or titanium or		
		"Ti")) and (mask\$3 or resist\$3 or		
		photoresist) same (\$4urethane adj3		
		\$4acrylate or \$4urethane adj3 \$4acrylate)	HCDAM.	2003/05/26 16:27
-	922	((((mask\$3 or resist\$3 or photoresist)	USPAT;	2003/03/20 10.2/
		same ((etch\$3 or chemical\$2 adj mil\$3 or	US-PGPUB; EPO; JPO;	
		deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same	IBM TDB	
		(aluminum or "Al" or steel or titanium or	TDI1_TDD	
		"Ti")) and (mask\$3 or resist\$3 or		
		photoresist) same (\$4acrylate or		
		\$4acrylate)   not ((((mask\$3 or resist\$3 or		
		photoresist) same ((etch\$3 or chemical\$2		
		adj mil\$3 or deoxidiz\$3 or anodiz\$3) and		
		metal)) and (mask\$3 or resist\$3 or		
		photoresist) same (aluminum or "Al" or		
		steel or titanium or "Ti")) and (mask\$3 or		
		resist\$3 or photoresist) same (\$4urethane		
		adj3 \$4acrylate or \$4urethane adj3		
		\$4acrylate))		
	26	((((mask\$3 or resist\$3 or photoresist)	USPAT;	2003/05/26 16:32
		same ((etch\$3 or chemical\$2 adj mil\$3 or	US-PGPUB;	
		deoxidiz\$3 or anodiz\$3) and metal)) and	EPO; JPO;	
		(mask\$3 or resist\$3 or photoresist) same	IBM_TDB	
		(aluminum or "Al" or steel or titanium or		
		"Ti")) and (mask\$3 or resist\$3 or		
		photoresist) same (\$4urethane adj3		
		\$4acrylate or \$4urethane adj3 \$4acrylate))		
		and (mask\$3 or resist\$3 or photoresist)		
		same (peel\$4 or pull\$4 or remov\$4 or		
	05.	lift\$3 adj off)	USPAT;	2003/05/26 16:32
-	854	<pre>(((((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or</pre>	US-PGPUB;	2000,00,20 10.02
		deoxidiz\$3 or anodiz\$3) and metal)) and	EPO; JPO;	
		(mask\$3 or resist\$3 or photoresist) same	IBM TDB	
		(aluminum or "Al" or steel or titanium or	122.	
		"Ti")) and (mask\$3 or resist\$3 or		
		photoresist) same (\$4acrylate or		
		\$4acrylate)) not ((((mask\$3 or resist\$3 or		
		photoresist) same ((etch\$3 or chemical\$2		
		adj mil\$3 or deoxidiz\$3 or anodiz\$3) and		
		metal)) and (mask\$3 or resist\$3 or		•
		photoresist) same (aluminum or "Al" or	•	
		steel or titanium or "Ti")) and (mask\$3 or		*
		resist\$3 or photoresist) same (\$4urethane		
		adj3 \$4acrylate or \$4urethane adj3		
	1	\$4acrylate))) and (mask\$3 or resist\$3 or		
		photoresist) same (peel\$4 or pull\$4 or		
	<u> </u>	remov\$4 or lift\$3 adj off)		

-	6	(((((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and	USPAT; US-PGPUB; EPO; JPO;	2003/10/13 21:12
		(mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or	IBM_TDB	
		photoresist) same (\$4urethane adj3 \$4acrylate or \$4urethane adj3 \$4acrylate)) and (mask\$3 or resist\$3 or photoresist)		
		same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off)) and (mask\$3 or resist\$3 or photoresist) same (scrib\$4 or cut\$4 or		
		mark\$4 or scrap\$4)		
_	1560	<pre>(mask\$3 or resist\$3 or photoresist) same (( deoxidiz\$3 or anodiz\$3) and metal)</pre>	USPAT; US-PGPUB; EPO; JPO; IBM TDB	2003/06/03 09:55
_	308	((mask\$3 or resist\$3 or photoresist) same (( deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4) adj3	USPAT; US-PGPUB; EPO; JPO;	2003/06/03 09:10
-	495	<pre>(mask\$3 or resist\$3 or photoresist) ((mask\$3 or resist\$3 or photoresist) same (( deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4 or pull\$4 or lift\$3 adj off) near3 (mask\$3 or resist\$3</pre>	IBM_TDB USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/06/03 09:11
-	511	or photoresist) ((mask\$3 or resist\$3 or photoresist) same (( deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4 or pull\$4 or lift\$3 adj off or cut\$4 or scrap\$4) near3	USPAT; US-PGPUB; EPO; JPO; IBM TDB	2003/06/03 09:12
-	24	<pre>(mask\$3 or resist\$3 or photoresist) ((mask\$3 or resist\$3 or photoresist) same (( deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4 or pull\$4 or lift\$3 adj off or cut\$4 or scrap\$4) near3 (mask\$3 or resist\$3 or photoresist) same</pre>	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 21:13
_	1	(seal\$3) (maskant or mask) and line adj sealant .same ((deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO;	2003/10/13 21:17
_	0	(maskant or mask) and line adj sealer same ((deoxidiz\$3 or anodiz\$3) and metal)	IBM_TDB USPAT; US-PGPUB; EPO; JPO;	2003/10/13 21:18
_	92	(216/42,44,47,48,101-102 or 430/320,323-324 or 205/122,135,153,188,320,324).ccls. and	IBM_TDB USPAT; ÙS-PGPUB; ÈPO; JPO;	2003/10/13 21:18
-	145	seal\$3 same mask\$3 (IRGACURE adj "1700") or (IRACURE adj "1700")	IBM_TDB USPAT; US-PGPUB; EPO; JPO;	2003/10/13 21:21
-	23	((IRGACURE adj "1700") or (IRACURE adj "1700")) and (wax or (synergist and triethanolamine))	IBM_TDB USPAT; US-PGPUB; EPO; JPO;	2003/10/13 21:24
_	3	((IRGACURE adj "1700") or (IRACURE adj "1700")) and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or radiat\$3) same (\$5watt adj per adj square adj \$5meter or "W/cm.sup.2" or	IBM_TDB USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:47
	7.00	"W/m.sup.2")	IIGDVa.	2003/10/13 16:13
_	762	(mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off) and \$4acrylate and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or radiat\$3) same (\$5watt adj per adj	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 10:13
		square adj \$5meter or \$1"W/cm.sup.2" or \$1"W/m.sup.2")		

_	40	(mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj	USPAT; US-PGPUB;	2004/01/16 09:49
		off) and \$4acrylate.ti,ab. and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or radiat\$3) same (\$5watt adj per	EPO; JPO; IBM_TDB	
-	6	adj square adj \$5meter or \$1"W/cm.sup.2") (((((mask\$3 or resist\$3 or photoresist)	USPAT;	2004/01/16 09:50
		same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same	US-PGPUB; EPO; JPO; IBM TDB	
		(aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or	_	
		photoresist) same (\$4urethane adj3 \$4acrylate or \$4urethane adj3 \$4acrylate)) and (mask\$3 or resist\$3 or photoresist)		
		same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off)) and (mask\$3 or resist\$3	,	
	25	or photoresist) same (scrib\$4 or cut\$4 or mark\$4 or scrap\$4) ((mask\$3 or resist\$3 or photoresist) same	USPAT;	2004/01/16 09:52
		(( deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4 or pull\$4 or lift\$3 adj off or cut\$4 or scrap\$4) near3 (mask\$3 or resist\$3 or photoresist) same	US-PGPUB; EPO; JPO; IBM_TDB	
-	1	(seal\$3) (maskant or mask) and line adj sealant	USPAŤ;	2004/01/16 09:53
		same ((deoxidiz\$3 or anodiz\$3) and metal)	US-PGPUB; EPO; JPO; IBM TDB	
_	0	(maskant or mask) and line adj sealer same ((deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO;	2004/01/16 09:54
-	95	(216/42,44,47,48,101-102.ccls. or 430/320,323-324.ccls. or 205/122,135,153,188,320,324.ccls.) and	IBM_TDB USPAT; US-PGPUB; EPO; JPO;	2004/01/16 09:59
	170	seal\$3 same mask\$3 (IRGACURE adj "1700") or (IRACURE adj "1700")	IBM_TDB USPAT; US-PGPUB;	2003/10/13 21:22
_	29	((IRGACURE adj "1700") or (IRACURE adj	EPO; JPO; IBM_TDB USPAT;	2004/01/16 10:02
	. 29	"1700")) and (wax or (synergist and triethanolamine))	US-PGPUB; EPO; JPO; IBM TDB	2004/01/16 10:02
-	3	((IRGACURE adj "1700") or (IRACURE adj "1700")) and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or	USPAT; US-PGPUB; EPO; JPO;	2004/01/16 09:48
		radiat\$3) same (\$5watt adj per adj square adj \$5meter or "W/cm.sup.2" or "W/m.sup.2")	IBM_TDB	
-	41	<pre>(mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj</pre>	USPAT; US-PGPUB;	2004/01/16 09:50
	ļ	off) and \$4acrylate.ti,ab. and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or radiat\$3) same (\$5watt adj per	EPO; JPO; IBM_TDB	
_ !	7	<pre>adj square adj \$5meter or \$1"W/cm.sup.2") (((((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or</pre>	USPAT; US-PGPUB;	2004/01/16 09:51
		<pre>deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or</pre>	EPO; JPO; IBM_TDB	·
		"Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4urethane adj3		
		\$4acrylate or \$4urethane adj3 \$4acrylate)) and (mask\$3 or resist\$3 or photoresist)		
		<pre>same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off)) and (mask\$3 or resist\$3 or photoresist) same (scrib\$4 or cut\$4 or</pre>		
		mark\$4 or scrap\$4)		

Page 3

,				0004/01/16 00 50
_	25	((mask\$3 or resist\$3 or photoresist) same	USPAT;	2004/01/16 09:52
	į į	(( deoxidiz\$3 or anodiz\$3) and metal)) and	US-PGPUB;	
		(peel\$4 or remov\$4 or scrib\$4 or pull\$4 or	EPO; JPO;	
		lift\$3 adj off or cut\$4 or scrap\$4) near3	IBM TDB	•
ļ		(mask\$3 or resist\$3 or photoresist) same	_	
		(seal\$3)		
	,	(maskant or mask) and line adj sealant	USPAT;	2004/01/16 09:53
	+	same ((deoxidiz\$3 or anodiz\$3) and metal)	US-PGPUB;	
		Same ( (deoxidizes of anodizes) and medal)	EPO; JPO;	
			IBM TDB	
		( ) model and line add coaler same	USPĀT;	2004/01/16 09:54
_	0	(maskant or mask) and line adj sealer same	US-PGPUB;	2001, 01, 10
1		((deoxidiz\$3 or anodiz\$3) and metal)	EPO; JPO;	
			IBM_TDB	2004/01/16 00:50
_	99	(216/42,44,47,48,101-102.ccls. or	USPAT;	2004/01/16 09:59
		430/320,323-324.ccls. or	US-PGPUB;	
		205/122,135,153,188,320,324.ccls.) and	EPO; JPO;	
		seal\$3 same mask\$3	IBM_TDB	
	31	((IRGACURE adj "1700") or (IRACURE adj	USPAT;	2004/01/16 10:02
		"1700")) and (wax or (synergist and	US-PGPUB;	
		triethanolamine))	EPO; JPO;	
		CII Condition of the co	IBM TDB	